



CMAS Interactions with Advanced Environmental Barrier Coatings Deposited via Plasma Spray- Physical Vapor Deposition

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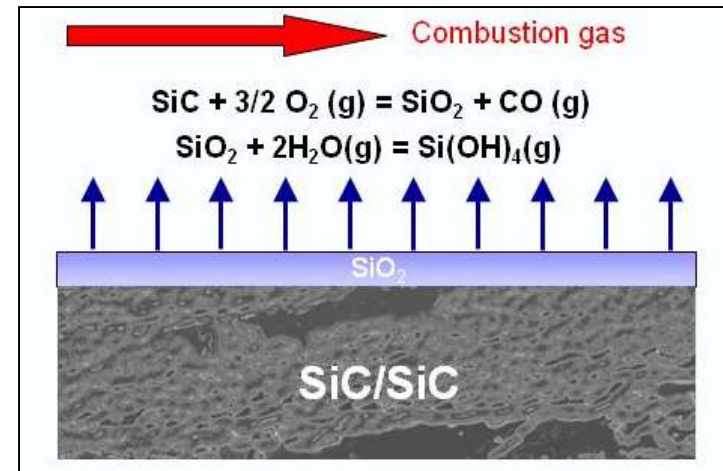
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as part of the Transformative Aeronautics Concepts (TACP) Program**

Motivation

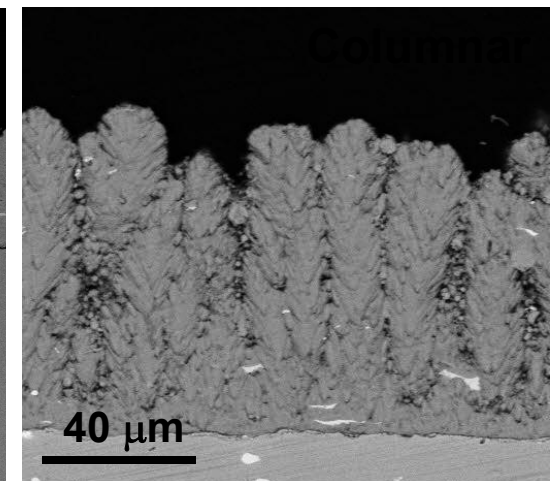
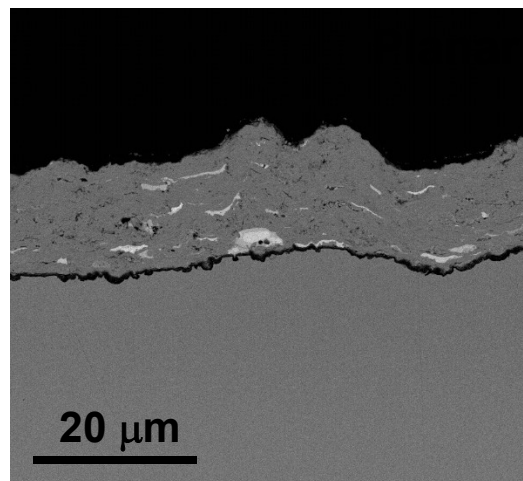
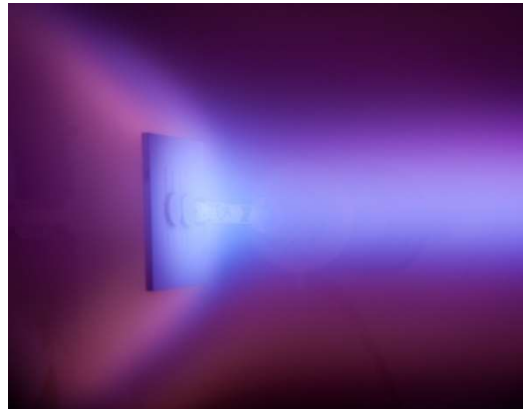
- Incorporation of Si-based ceramics into turbine hot section has substantial benefits
 - Limited by water vapor attack
- Environmental barrier coatings (EBCs) are necessary to protect the underlying ceramic
- Current NASA goals require durable coating systems at 1482C (2700F)
 - Limited recession and good adhesion
- Traditional processing methods may not be able to meet the requirements
 - Plasma Spray-Physical Vapor Deposition (PS-PVD)





Plasma Spray-Physical Vapor Deposition (PS-PVD)

- Bridges the gap between plasma spray and vapor phase methods
 - Variable microstructure
 - Multilayer coatings with a single deposition
- Low pressure (70-1400 Pa)
High power (>100 kW)
 - Temperatures 6,000-10,000K
- High throughput¹
 - 0.5 m² area, 10 μm layer in < 60s
- Material incorporated into gas stream
 - Non line-of-sight deposition
- Attractive for a range of applications
 - Solid oxide fuel cells, gas sensors, etc.

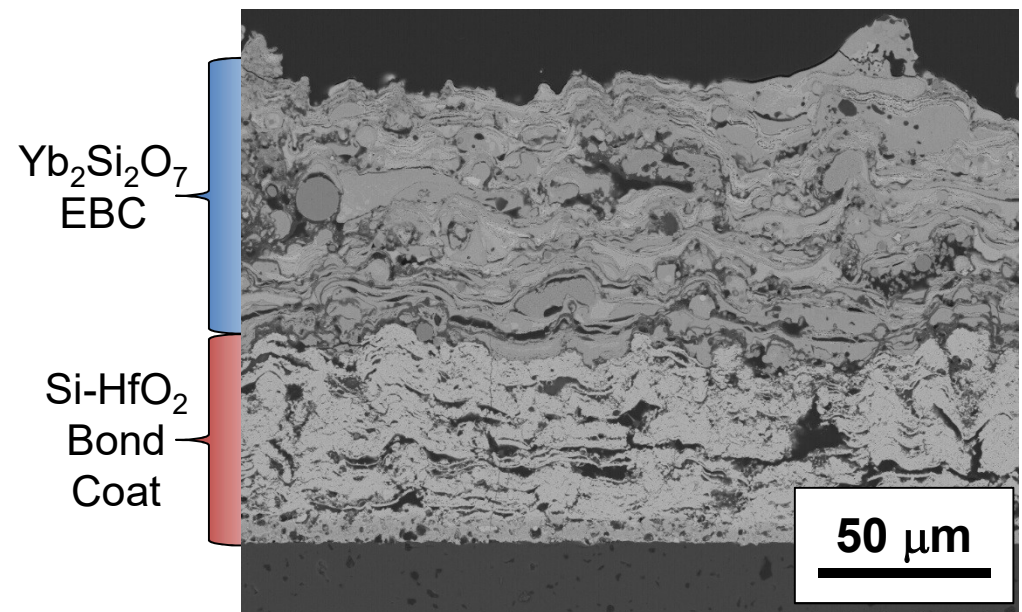


¹A. Refke, et al. *Proceedings of the International Thermal Spray Conference, May 14-18, (Beijing, China), 705-10 (2007).*

Yb₂Si₂O₇/Si-HfO₂ EBCs

- Bulk SiC substrates 0.5" x 0.75"
- Bond coat was Si-HfO₂
 - “Bricks and Mortar” structure
 - Starting powder 30/70 mol% HfO₂/Si
- SiO₂-lean Yb-silicate
 - 35 mol% Yb₂O₃ bal SiO₂
 - Fully reacted 85/15 wt% Yb₂Si₂O₇/Yb₂SiO₅
 - After deposition coating contained some free SiO₂ (~10 wt%)
- Heated in air to 1300°C for 20hr prior to CMAS exposure

As-deposited 2-layer EBC

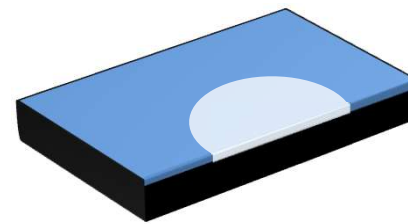
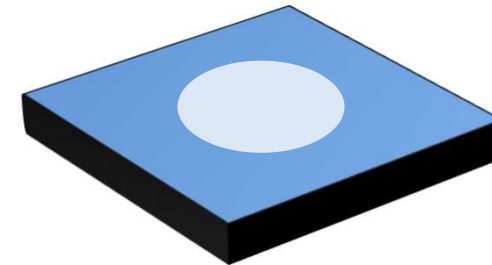
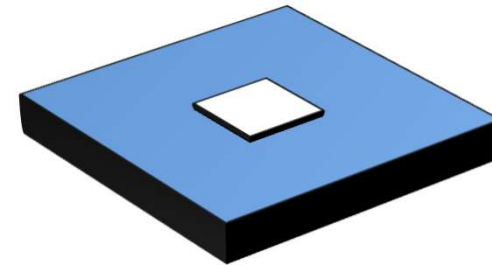


CMAS Exposure

- CMAS composition was melted at 1500°C and quenched
- CMAS was milled and tape cast at a loading of $\sim 29 \text{ mg/cm}^2$
- Tape area for exposure $\sim 2 \text{ mm} \times 2 \text{ mm}$
 - Total tape weight before burnout 1.50 - 2.0 mg
- Binder burnout at 500°C (6 hr)
- Ramp rate $\sim 5^\circ\text{C/min}$ to target temp
- Cross-section through center of reacted zone

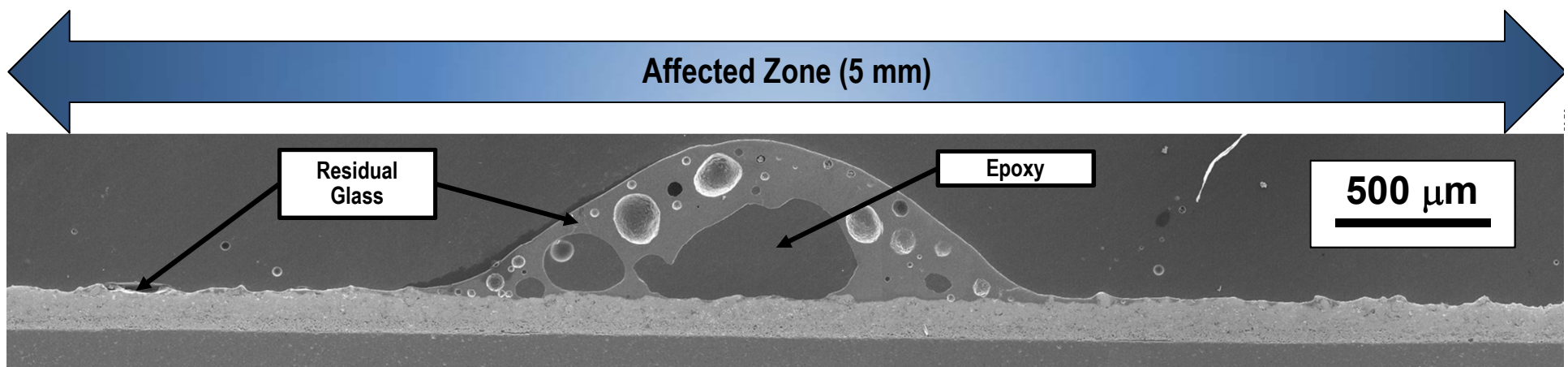
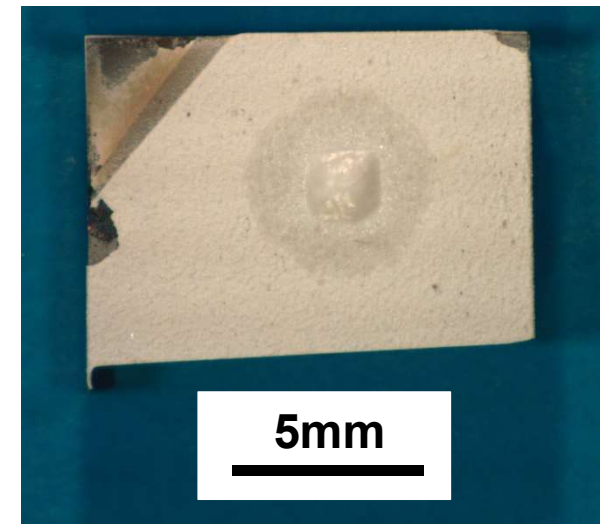
CMAS Composition (mol%)

CaO	MgO	Al ₂ O ₃	SiO ₂	Na ₂ O	K ₂ O	Fe ₂ O ₃
23.3	6.4	3.1	62.5	4.1	0.5	0.05



1200°C/10hr

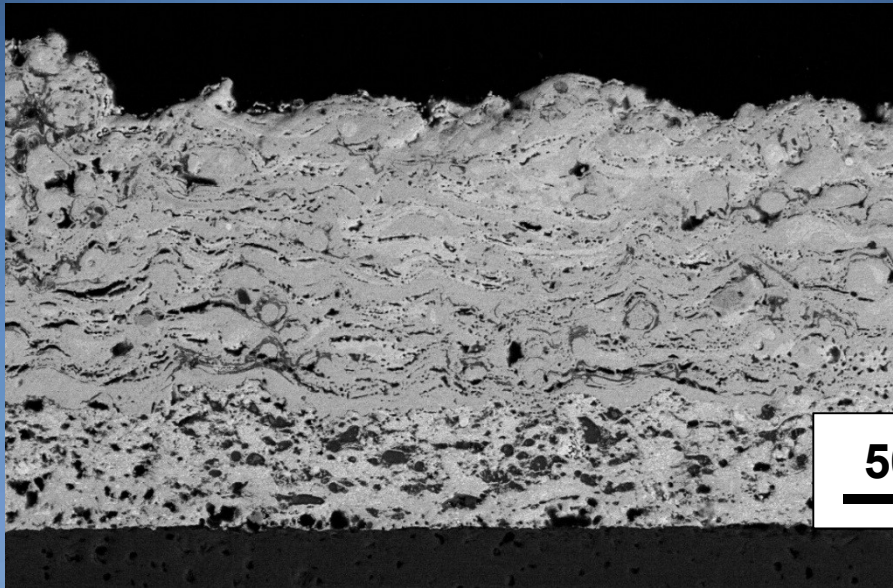
- Tape became shiny and exhibited wetting on the surface of the coating
- Total 'affected zone' was ~5mm
- Macro image showed the glass did not go fully molten



1200°C/10hr

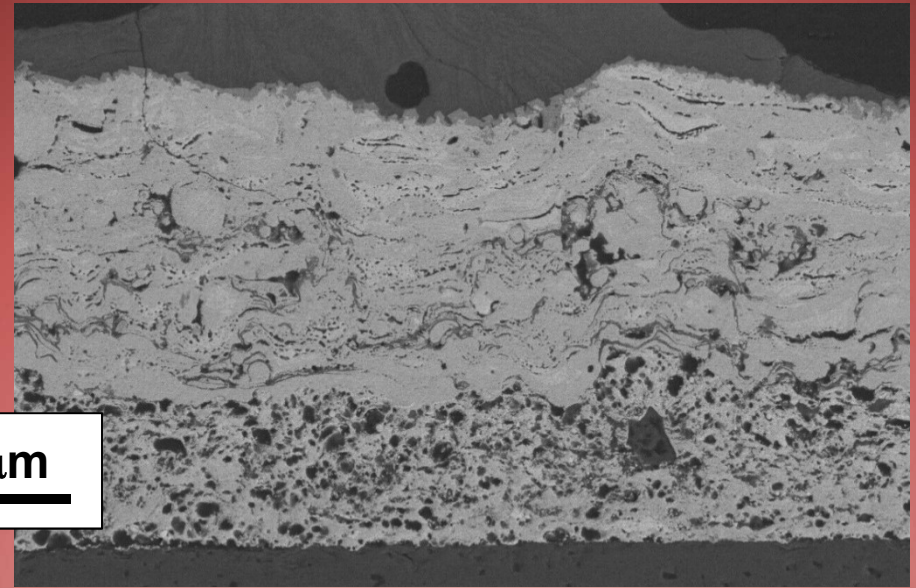


Unreacted



50 μm

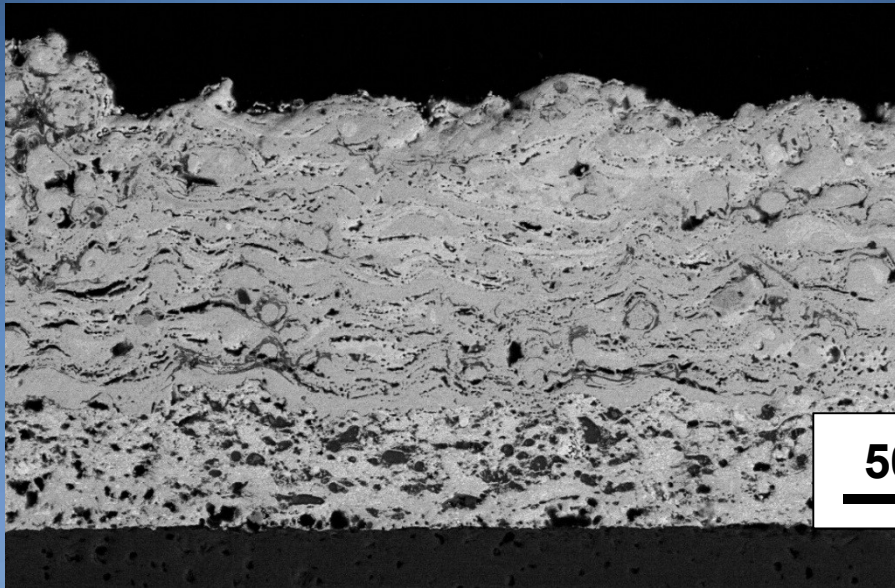
With CMAS



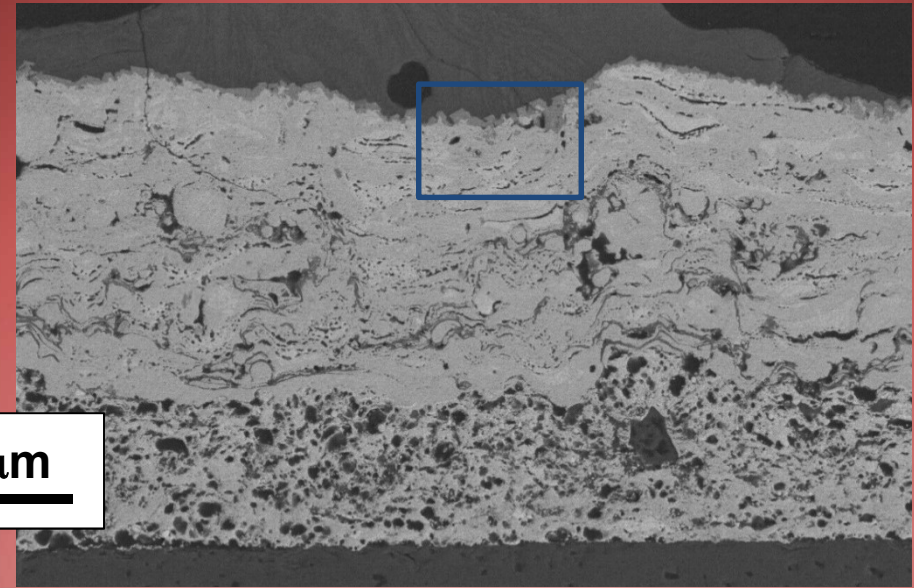
- Glass did not significantly attack or infiltrate the EBC
- Interaction zone with top of EBC layer of $\sim 10\mu\text{m}$
 - Si:Ca:Yb ratio of 3:1:1
- Underlying EBC and bond coat did not show any signs of glass infiltration

1200°C/10hr

Unreacted



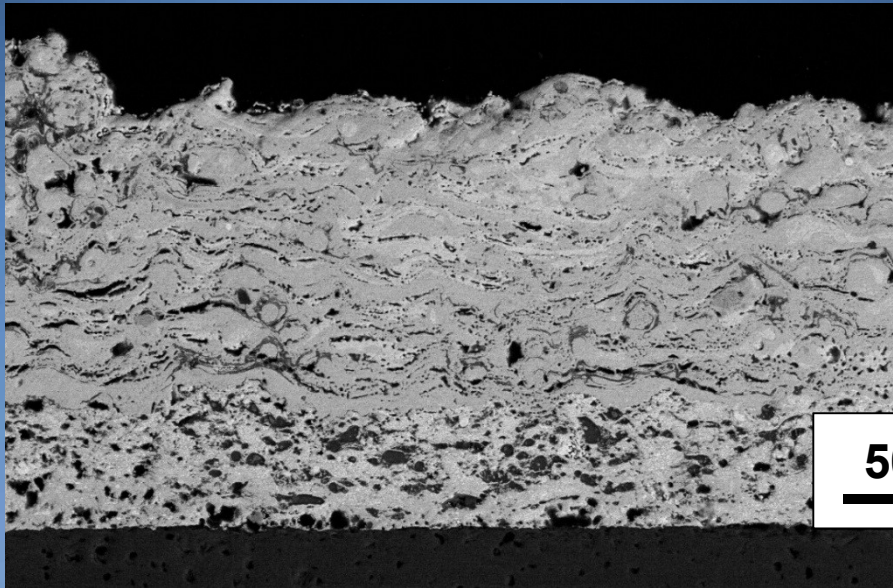
With CMAS



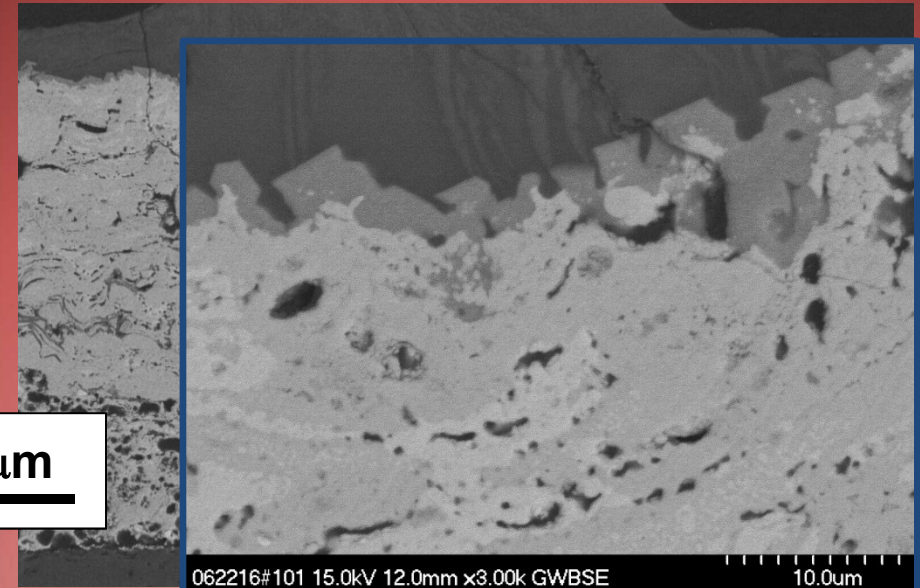
- Glass did not significantly attack or infiltrate the EBC
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- Underlying EBC and bond coat did not show any signs of glass infiltration

1200°C/10hr

Unreacted



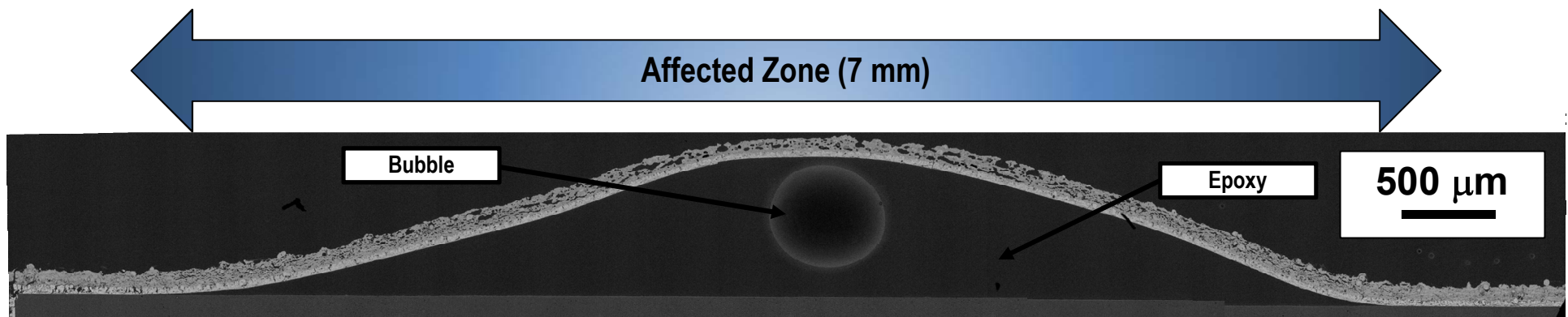
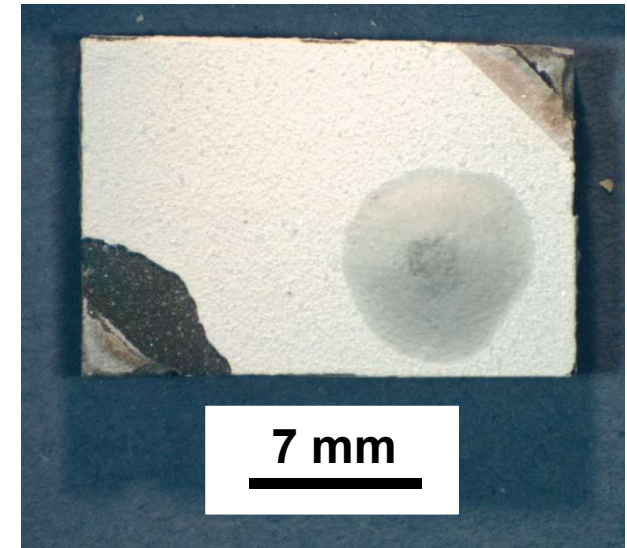
With CMAS



- Glass did not significantly attack or infiltrate the EBC
- Interaction zone with top of EBC layer of ~10μm
 - Si:Ca:Yb ratio of 3:1:1
- Underlying EBC and bond coat did not show any signs of glass infiltration

1300°C/10hr

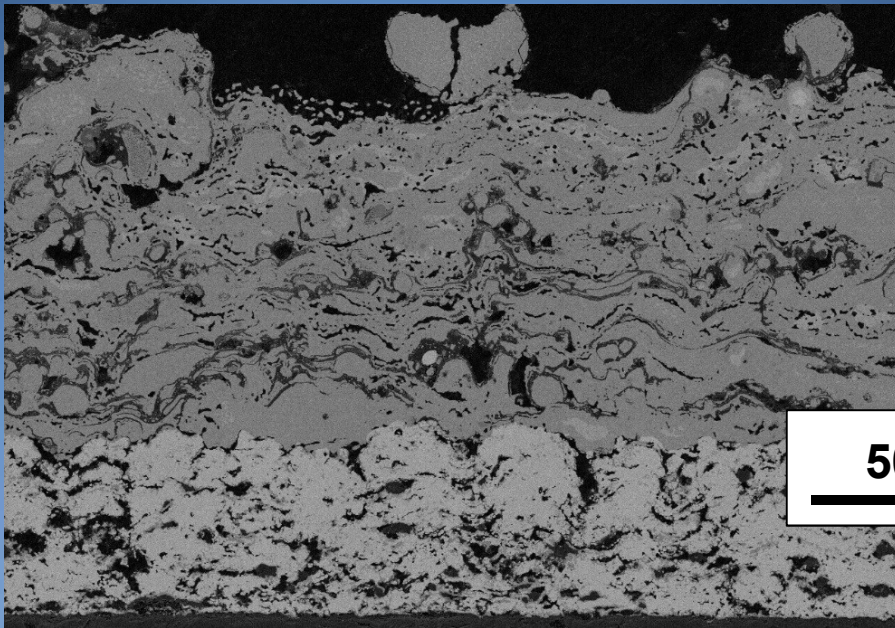
- Tape completely wet surface and coating raised off surface by ~0.75mm
- Total 'affected zone' was ~7mm
- Macro image showed coating was thinned near the center of the tape



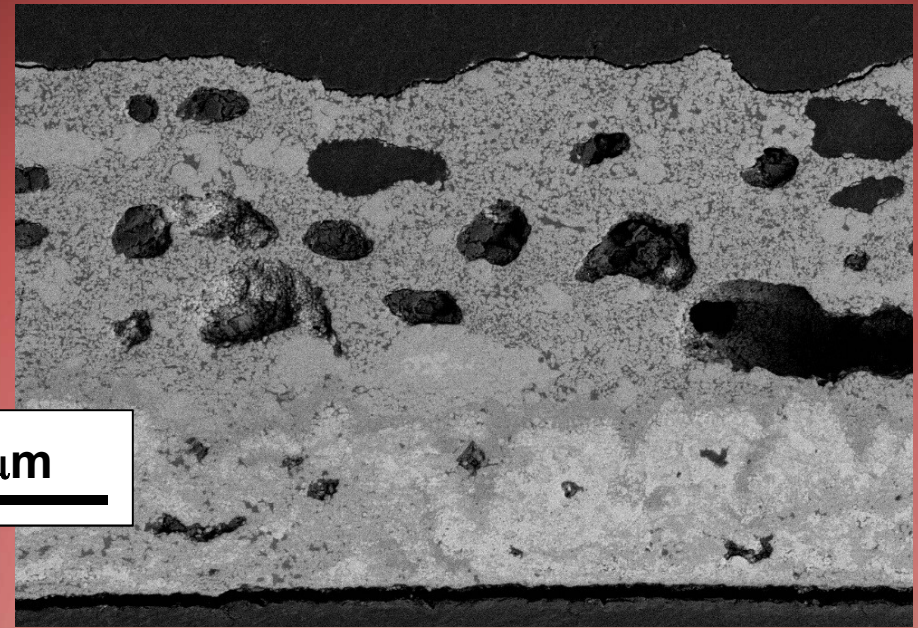
1300°C/10hr



Unreacted



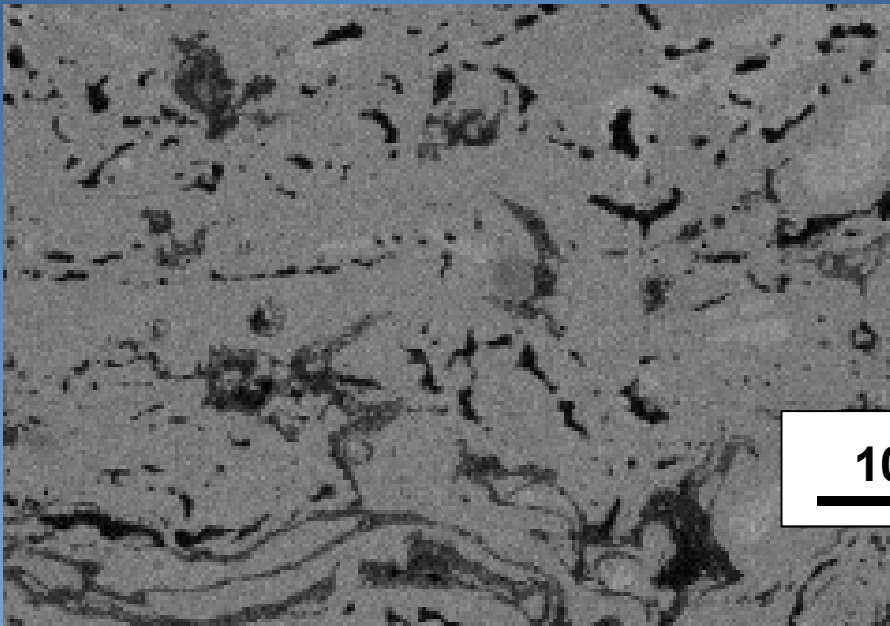
With CMAS



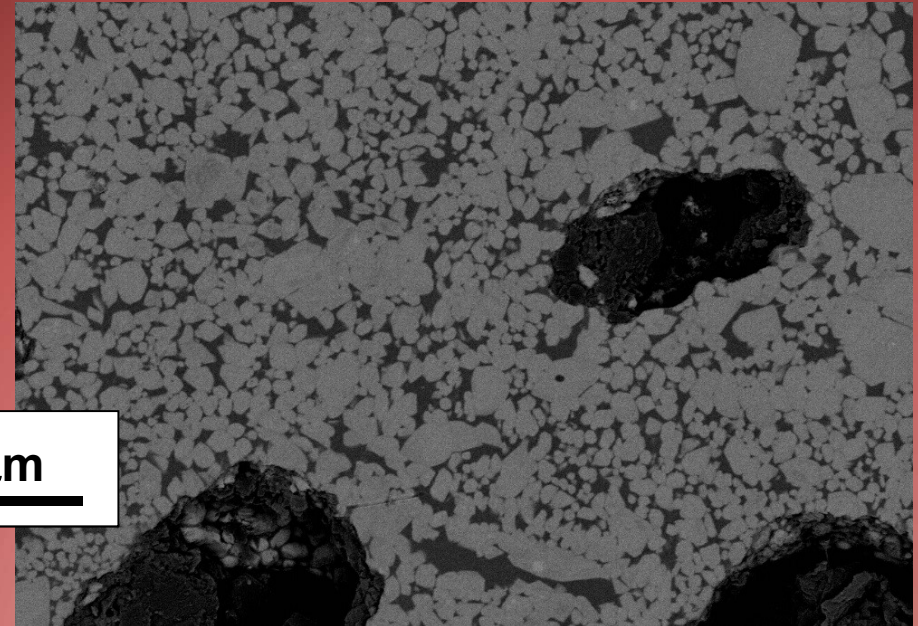
- Glass penetrated through both the EBC and bond coat layers
 - Residual glass had similar to starting composition (Si:Ca 3:1)
- Top coat had large pores and coating material suspended in residual glass
 - Much more homogeneous, no sign of Yb_2SiO_5
- Bond coat significantly densified and HfO_2 had more rounded microstructure
 - Little or no Si/SiO₂ present after reacting with CMAS

1300°C/10hr (Top Coat)

Unreacted



With CMAS

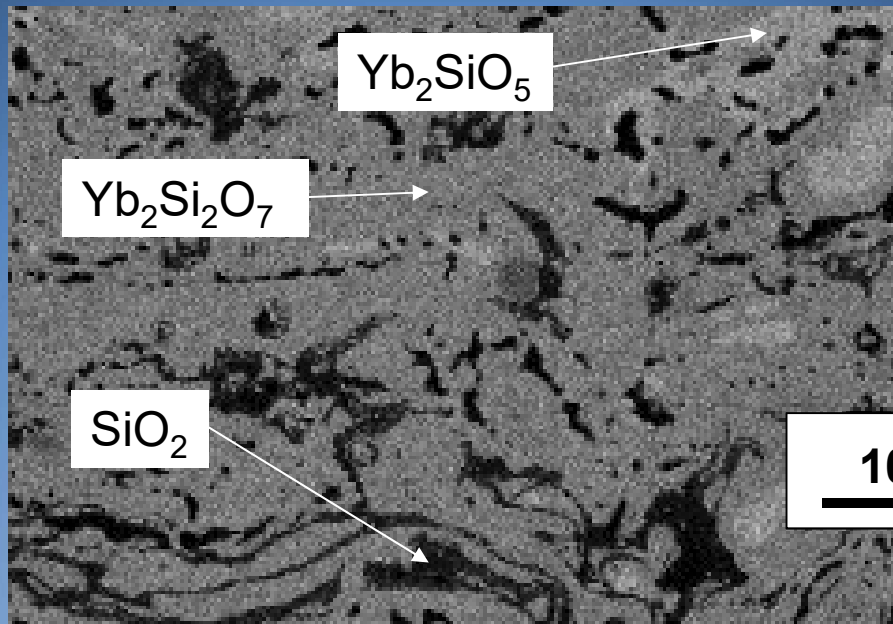


10 μm

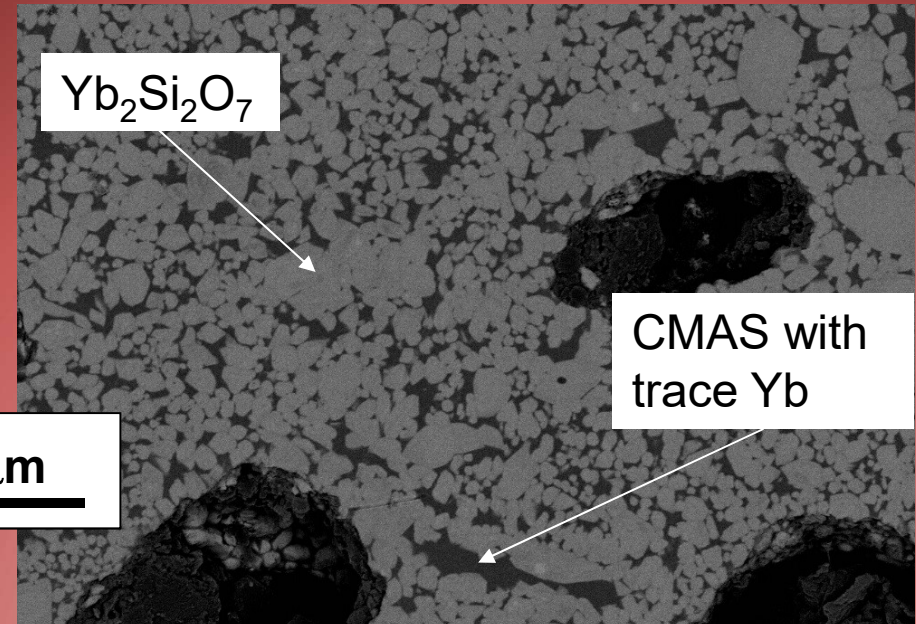
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Unreacted



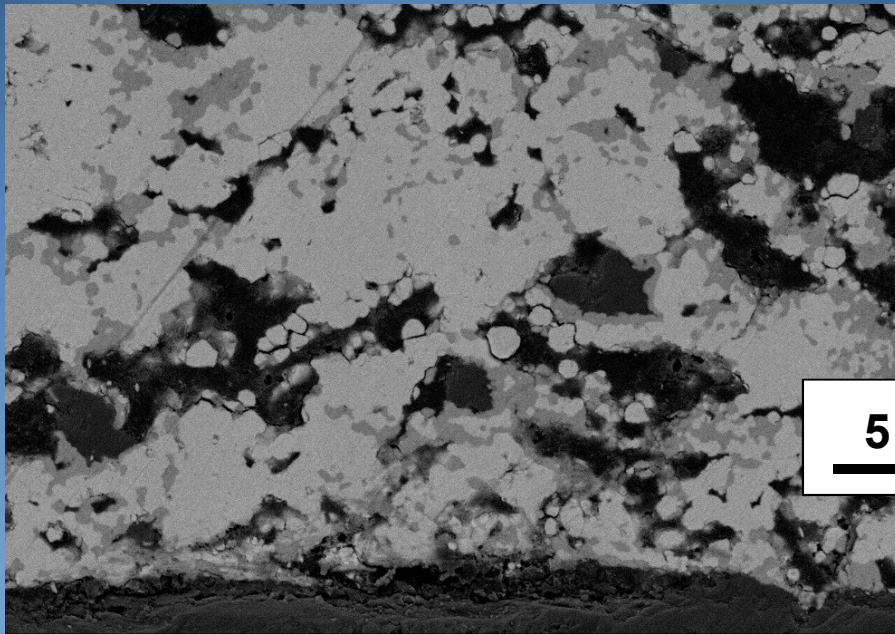
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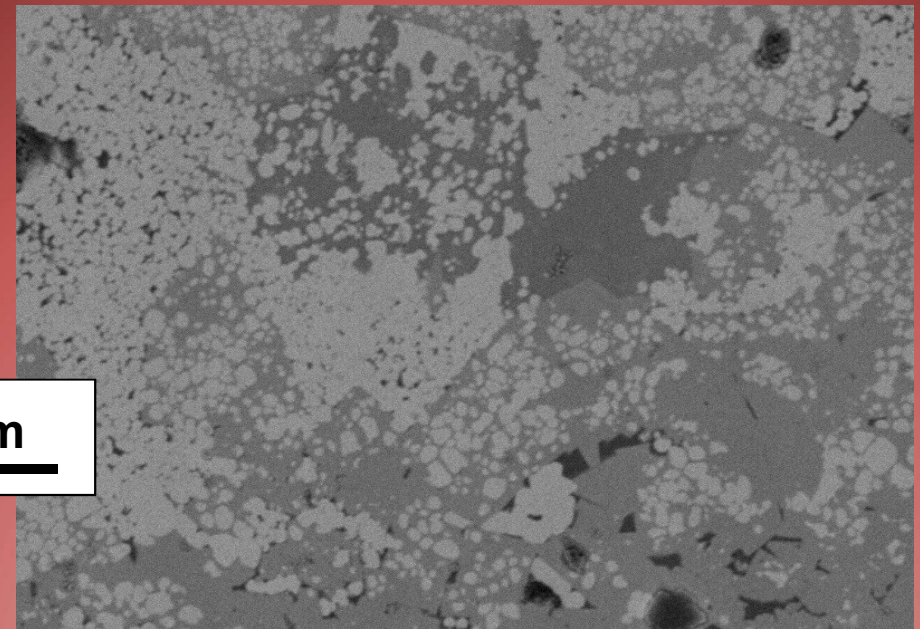
1300°C/10hr (Bond Coat)

Unreacted



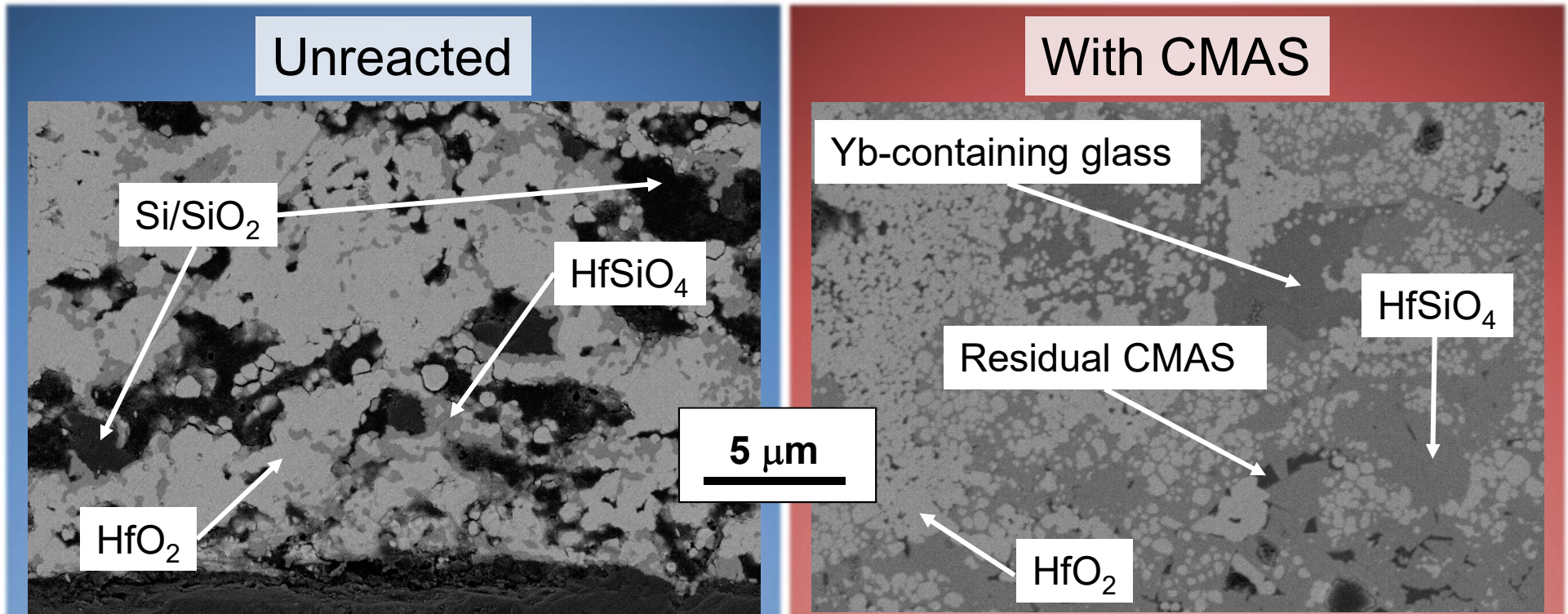
5 μm

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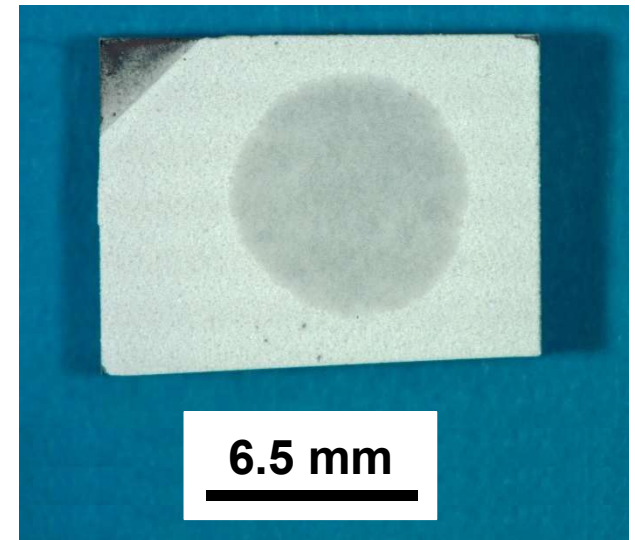
1300°C/10hr (Bond Coat)



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 - Residual glass had similar to starting composition (Si:Ca 3:1)
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1400°C/1hr

- Tape completely wet surface and roughened surface of the coating
- Total 'affected zone' was ~6.5mm
- Macro image shows significant porosity in the EBC top coat

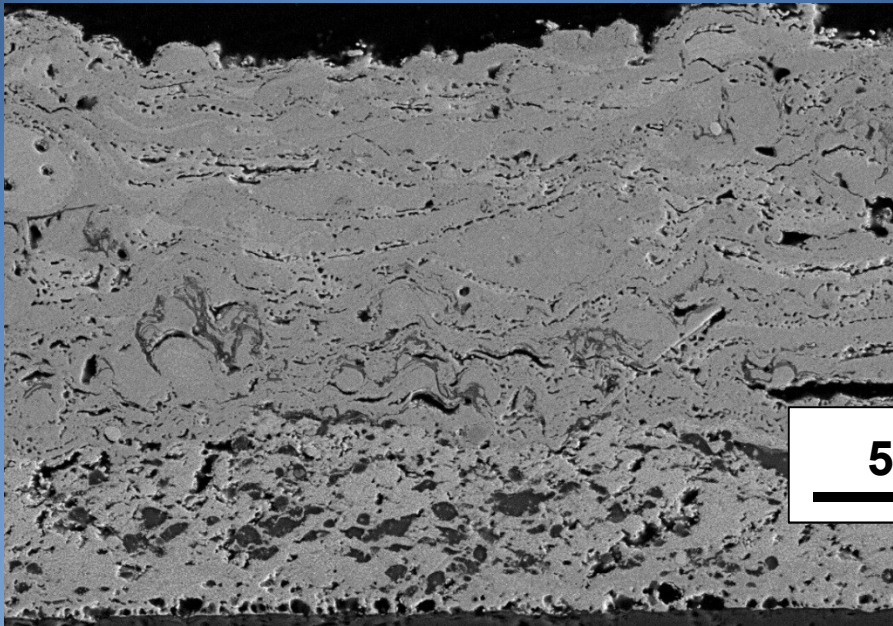


Affected Zone (6.5 mm)

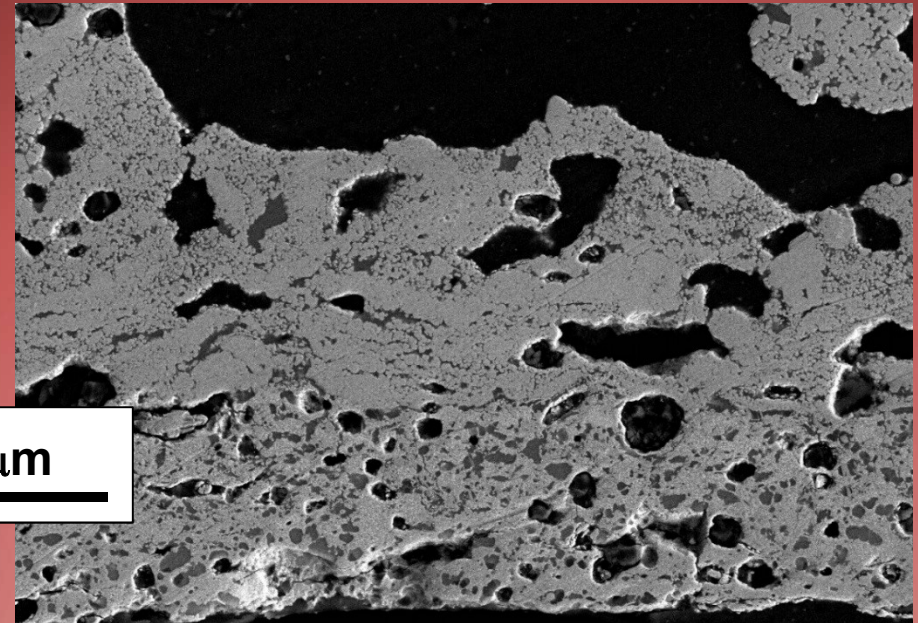
500 μm

1400°C/1hr

Unreacted



With CMAS

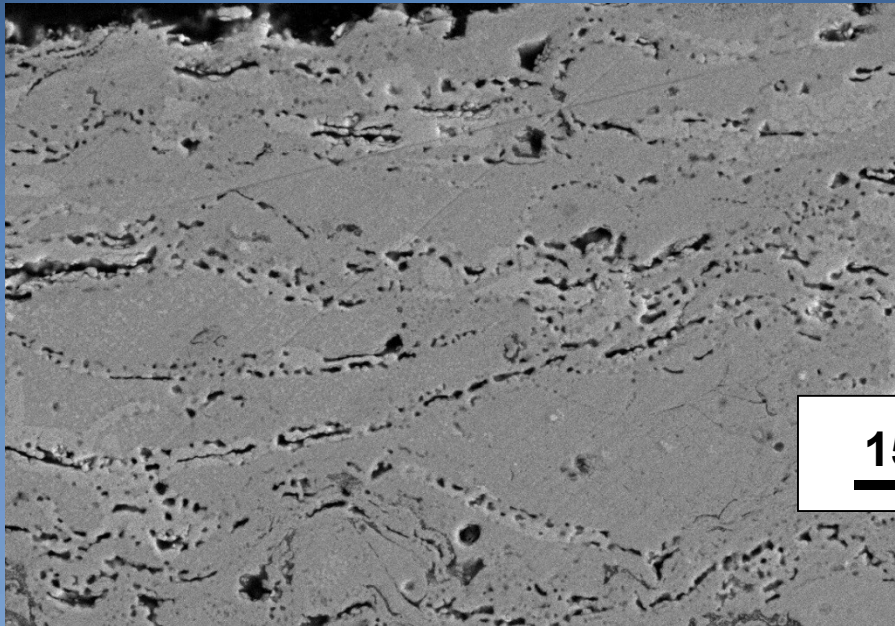


50 μm

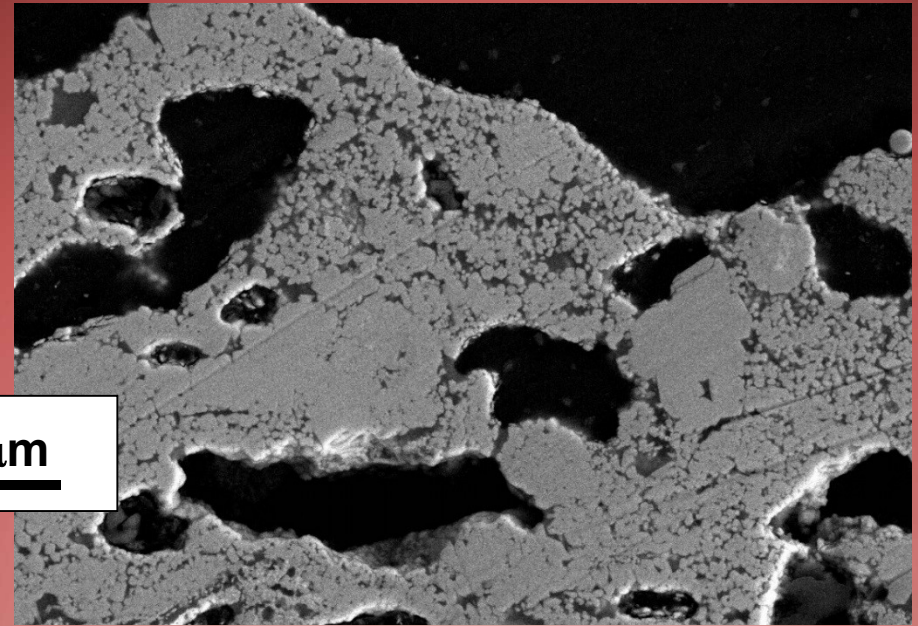
- Even after 1 hour at 1400C, there was significant damage to the coating
- Yb-silicate topcoat was aggressively attacked, resulting in large pores within mixture of residual glass and $\text{Yb}_2\text{Si}_2\text{O}_7$
- Bond coat porosity increased significantly although evidence of CMAS presence was limited
 - Si/SiO₂ present and limited evidence of dissolution/reprecipitation

1400°C/1hr (Top Coat)

Unreacted



With CMAS

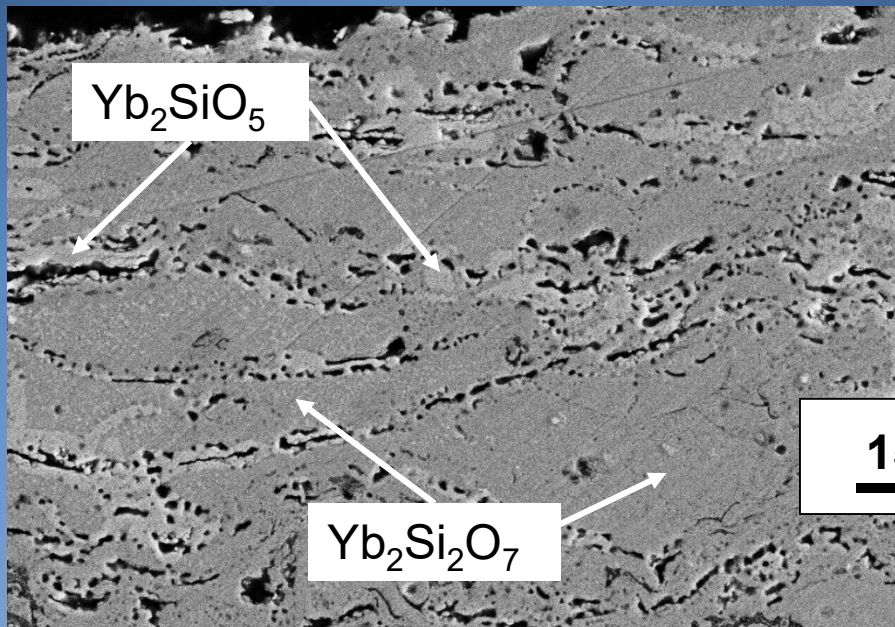


15 μm

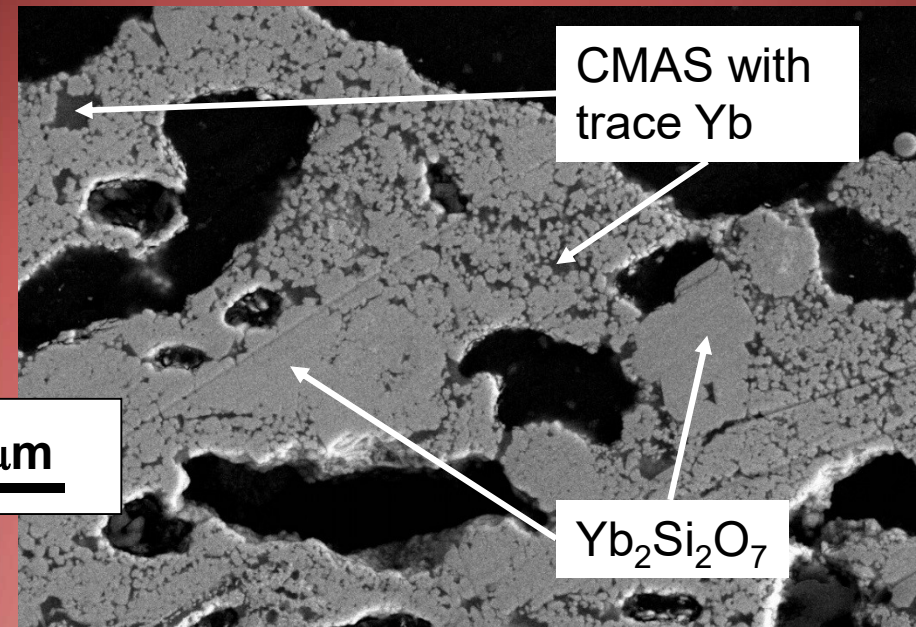
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Unreacted



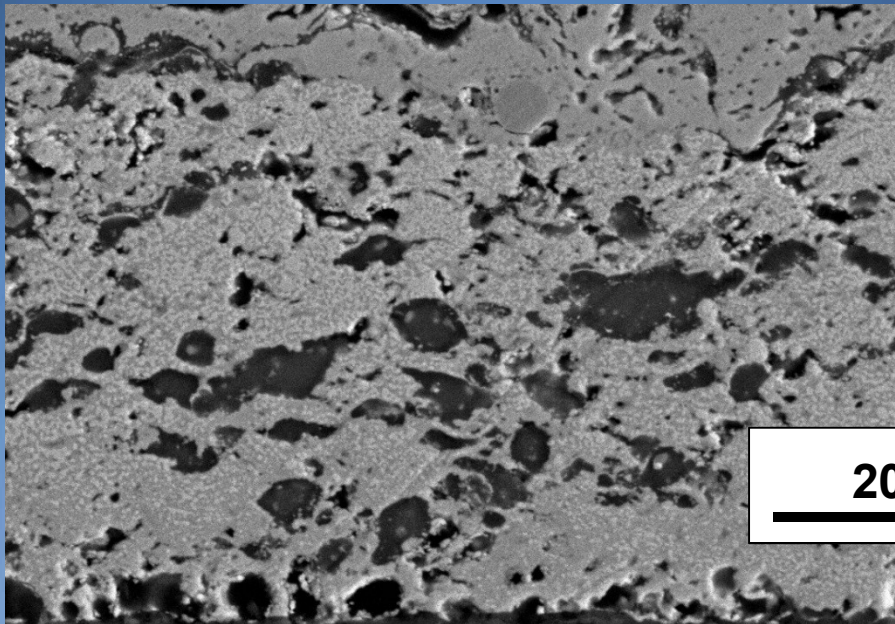
With CMAS



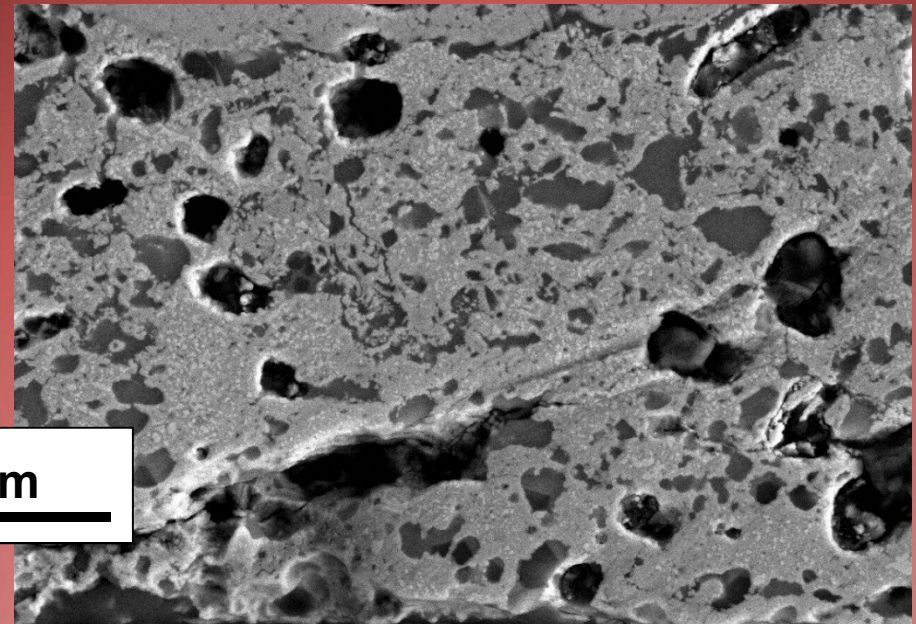
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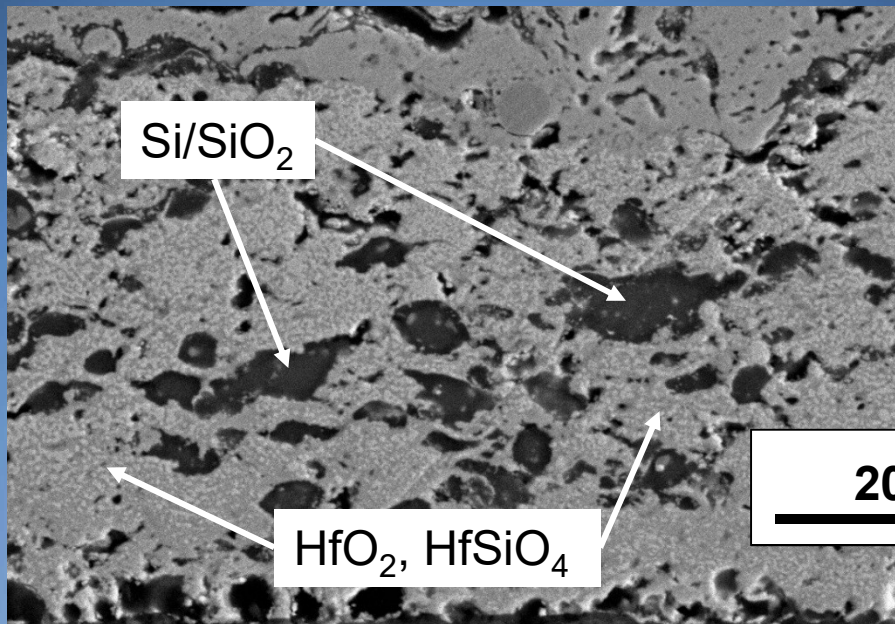
With CMAS



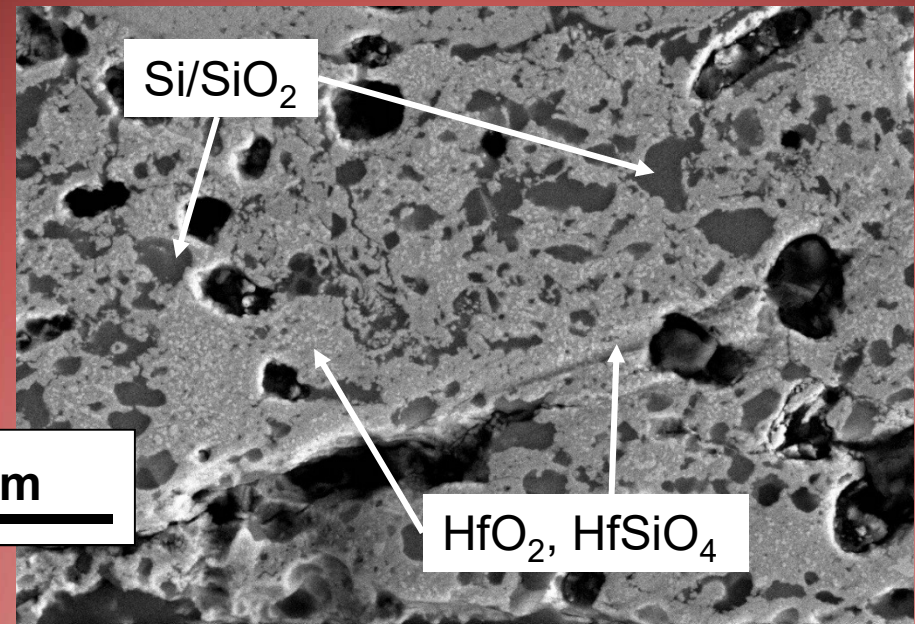
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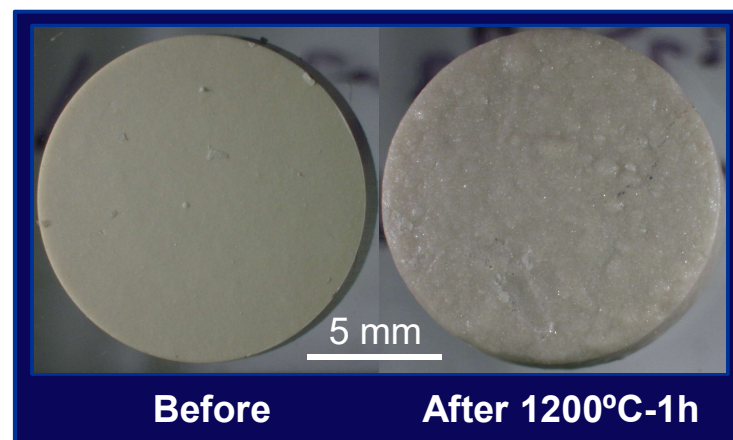
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Identifying Phase Development using XRD

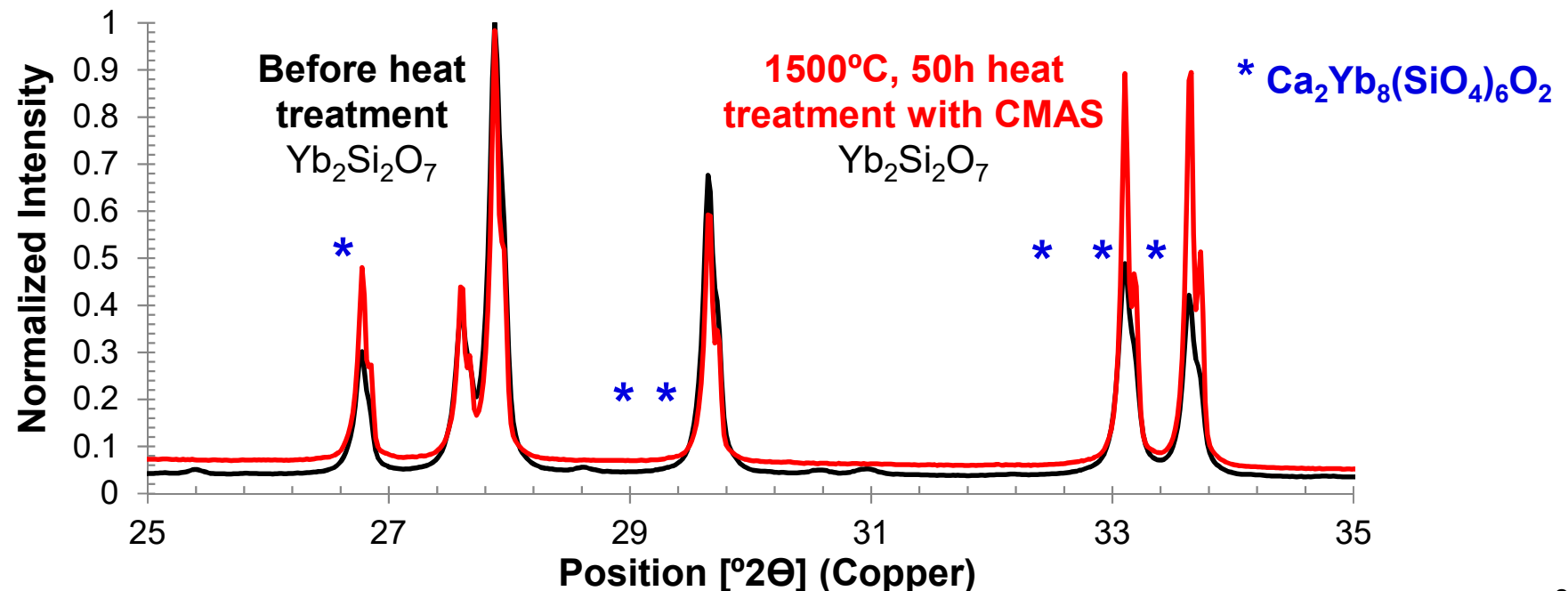
- Heat treated powder pellets in air
 - 75/25 wt.% EBC powder ($\text{Yb}_2\text{Si}_2\text{O}_7$) with CMAS glass
 - 75/25 wt.% “Bond Coat” material (HfSiO_4) with CMAS glass
 - Heated in air to 1200, 1300, 1400 and 1500°C for 50h
- Evaluate reacted pellet using X-ray diffraction (XRD) to compare with observed coating results





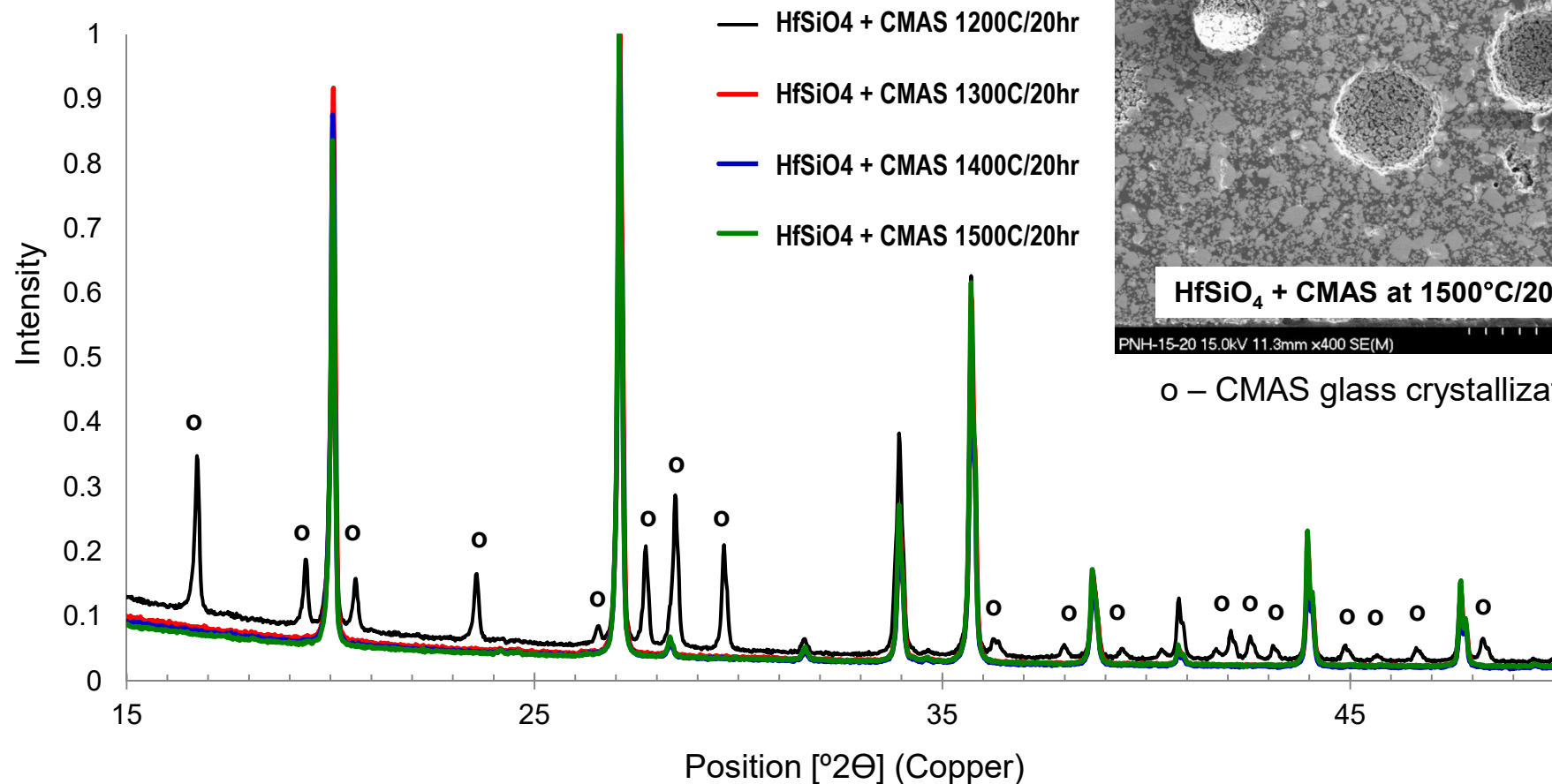
Solid State Reaction of CMAS with $\text{Yb}_2\text{Si}_2\text{O}_7$

- $\text{Ca}_2\text{Yb}_8(\text{SiO}_4)_6\text{O}_2$ (silicate oxyapatite) not detected in reacted powder pellets by XRD
 - Only $\text{Yb}_2\text{Si}_2\text{O}_7$ phase detected
- Previous study¹ suggests some dissolution occurs, though not quantifiable by XRD
 - Crystalline $\text{Yb}_2\text{Si}_2\text{O}_7$ content decreased with no second phase developing



¹ F. Stolzenburg, M.T. Johnson, K.N. Lee, N.S. Jacobson, K.T. Faber, *Surface and Coatings Technology* 284 (2015) 44-50.

Solid State Reaction of CMAS to HfSiO_4



Phases Detected in All Pellets

Hafnium Silicate (HfSiO_4)
 Hafnium Oxide (HfO_2)
 Silicon Oxide (SiO_2)

SEM/EDS confirms CMAS composition suggesting
 CMAS is amorphous glass $\geq 1300^{\circ}\text{C}$



Conclusions

- A two-layer environmental barrier coating system of Si-HfO_2 and $\text{Yb}_2\text{Si}_2\text{O}_7$ was deposited via Plasma Spray-Physical Vapor Deposition (PS-PVD) and samples were exposed to CMAS isothermally in air at a loading of 29 mg/cm^2 .
- At 1200°C the attack of the EBC topcoat was limited to less than 10 microns, but the reaction layer was not an oxyapatite phase.
- Above 1200°C the CMAS composition aggressively attacked the Yb-silicate resulting in dissolution of the topcoat but no additional phases were observed.
- The Si-HfO_2 layer was infiltrated with CMAS, which reached the substrate, but the bond coat remained intact (albeit with some glass present).
- Phase analysis of heat treated mixtures of CMAS with $\text{Yb}_2\text{Si}_2\text{O}_7$ and HfSiO_4 provided similar results of limited secondary phases forming from reaction.
- Overall, these two-layer systems do not provide adequate protection against CMAS either from penetration or melt stabilization.



Acknowledgements

- Kang Lee
- Ed Sechkar
- Scott Panko
- Nate Jacobson
- Terry McCue
- Rick Rogers
- Joy Buehler